JC18 Rec'd PCT/PTO 01 AUG 2005.

10/944159

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Attorney Docket # 5367-191PUS

Patent

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re National Phase PCT Application of

Peter STAUSS et al.

Int'l PCT Appln. No.: PCT/DE2004/000121

Int'l Filing Date:

27 January 2004

For:

Thin-Film Semiconductor Component and Production Method for said Component

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Check box if applicable:

DUPLICATE

## **INFORMATION DISCLOSURE STATEMENT**

SIR:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO/SB/08a. Copies of the listed non-U.S. documents are also enclosed.

USP 6,559,075 corresponds to DE 196 40 594 B1.

USP 6,181,855 corresponds to DE 195 46 443 A1.

USP 6,135,645 corresponds to DE 197 06 279 A1.

DE 4 324 318 corresponds to WO 95/03628.

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It is respectfully requested that the above information be considered by the Examiner and that the copy of the enclosed Form PTO/SB/08a be returned indicating that such information has been considered.

In accordance with 37 C.F.R §§1.97(g) and (h), the filing of this Information Disclosure Statement should not be construed as a representation that a search has been made or that information cited is, or is considered to be, material to patentability as defined in §1.56(b), or that any cited document listed or attached is (or constitutes) prior art. Unless otherwise indicated, the date of publication indicated for an item is taken from the face of the item and Applicant(s) reserve(s) the right to prove that the date of publication is in fact different.

If any fees or charges are deemed required at this time in connection with the application, the same may be charged to our Patent and Trademark Office Deposit Account No. 03-2412.

Respectfully submitted, COHEN, PONTANI, LIEBERMAN & PAVANE

By:

Thomas Langer

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Dated: August 1, 2005

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PTO/SB/08A (04-03)

Approved for use through 04/30/2003. OMB 0651-0031

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Substitute for	r Form 1449/PTO			Complete if Known		
				Application Number		
INFORMATION DISCLOSURE				Filing Date		
	_			First Named Inventor	Peter STAUSS	
STATEMENT BY APPLICANT (Use as many sheets as necessary)				Art Unit		
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Sheet	1	of	2	Attorney Docket Number	5367-191PUS	

			U.S. PATENT	DOCUMENTS	
Examiner Initials*	Cite No. 1	Document Number  Number-Kind-Code <sup>2</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		US-4,749,840 A	06/07/1988	Piwczyk	
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		US-6,071,795	06/06/2000	Cheung et al.	

Examiner	Cite	FOF Foreign Patent Document	Pages, Columns,	76		
Initials*	No. '	Country Code <sup>3-</sup> Number <sup>4-</sup> Kind- Code <sup>5</sup> (if known	MM-DD-YYYY	Applicant of Cited Document	Lines, Where Relevant Passages	
		WO 98/14986	04/09/1998	Ambacher		
		JP 2000 196197	11/17/2000	Xerox Corp.		Abstract
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·		DE 43 24 318 C1	01/12/1995	Siemens AG	-	
		DE 198 21 544 A1	12/16/1999	Lorenzen et al.		Abstract
		DE 197 06 279 A1	08/20/1998	Siemens AG		
Exam Signa	niner			Date Considered		

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Substitute fo	or Form 1449/PTO				Complete if Known		
					Application Number	10/544159	
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT					First Named Inventor	Peter STAUSS	
STAT				ANT	Art Unit		
	(Use as many sh	ieets as n	ecessary)		Examiner Name		
Sheet	2	of	2		Attorney Docket Number	5367-191PUS	

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	Examiner Signature	Date Considered	
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